

Cluster 4. Functional materials project C16029

University of Twente, Department of Elastomer Technology and Engineering, 7500AE, Enschede, The Netherlands



# Molecular layer deposition and plasma deposition to produce functionalized silica

# S. KIM<sup>a</sup>, J.R. van Ommen<sup>b</sup>, J. Davin<sup>c</sup>, C. Recker<sup>c</sup>, J. Schoeffel<sup>c</sup>, W. K. Dierkes<sup>a</sup>, A. Blume<sup>a</sup>

<sup>a</sup>Department of Elastomer Technology and Engineering, University of Twente, 7500AE Enschede, Netherlands <sup>b</sup>Department of Chemical Engineering, Delft University of Technology (TU Delft), 2629HZ Delft, Netherlands <sup>c</sup>Continental Reifen Deutschland GmbH, 30419 Hannover, Germany

## Introduction

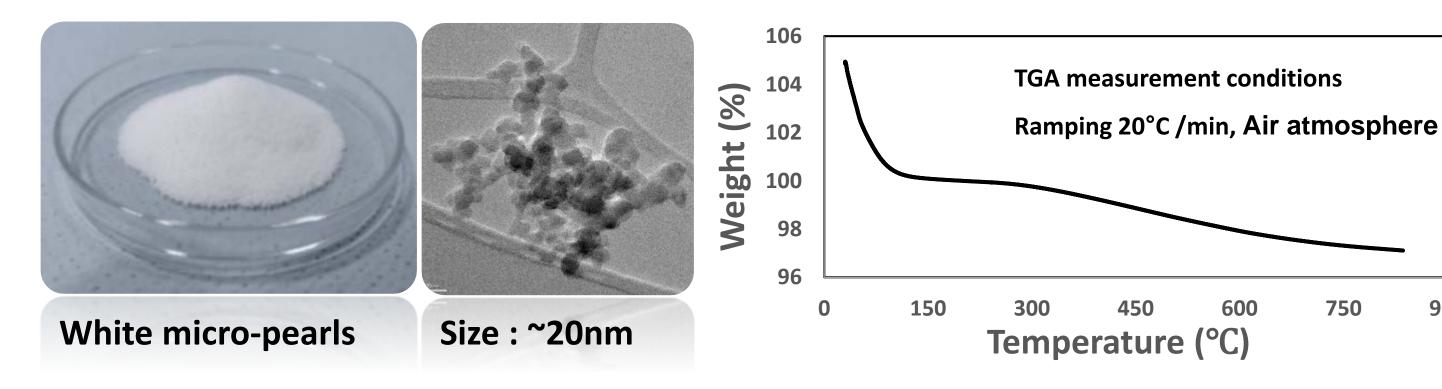
The aim of this project is to investigate molecular layers of organic coatings deposited on silica particles – to make them directly compatible with tire elastomers – reducing the rolling resistance of the tires significantly, and thus the global energy consumption in automotive transportation.

900

# **Results and discussion**

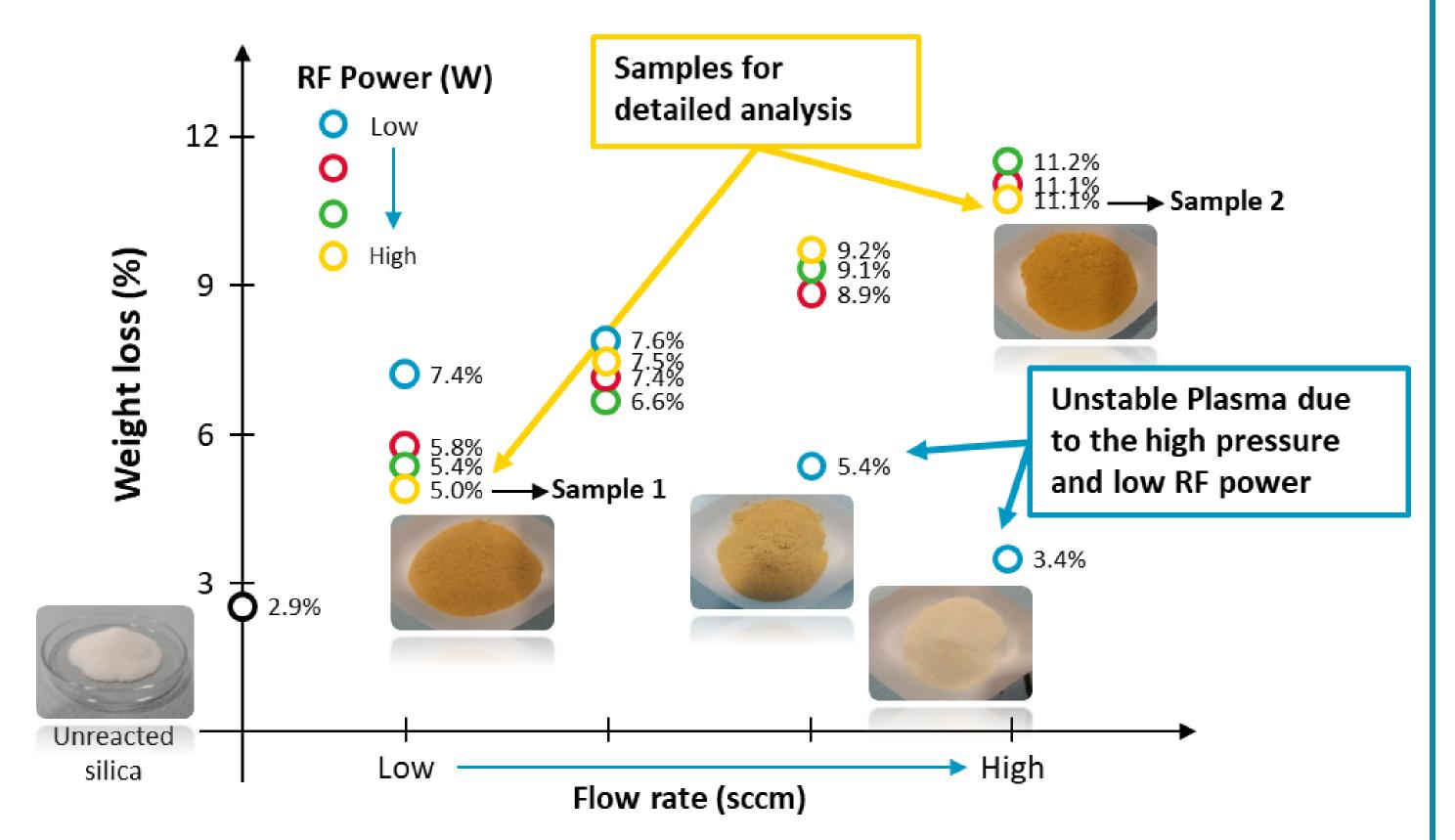
#### Silica : Ultrasil 7005

Specifications				TGA results		
BET surface area (N2)	CTAB surface area	Loss on drying 2h, 105°C	pH value	Water content (<200°C)	Weight loss (200~850°C)	Number of Silanol groups
m²/g	m²/g	%		%	%	SiOH/nm <sup>2</sup>
190	>175	≤ 7	6.0	4.9	2.9	~10

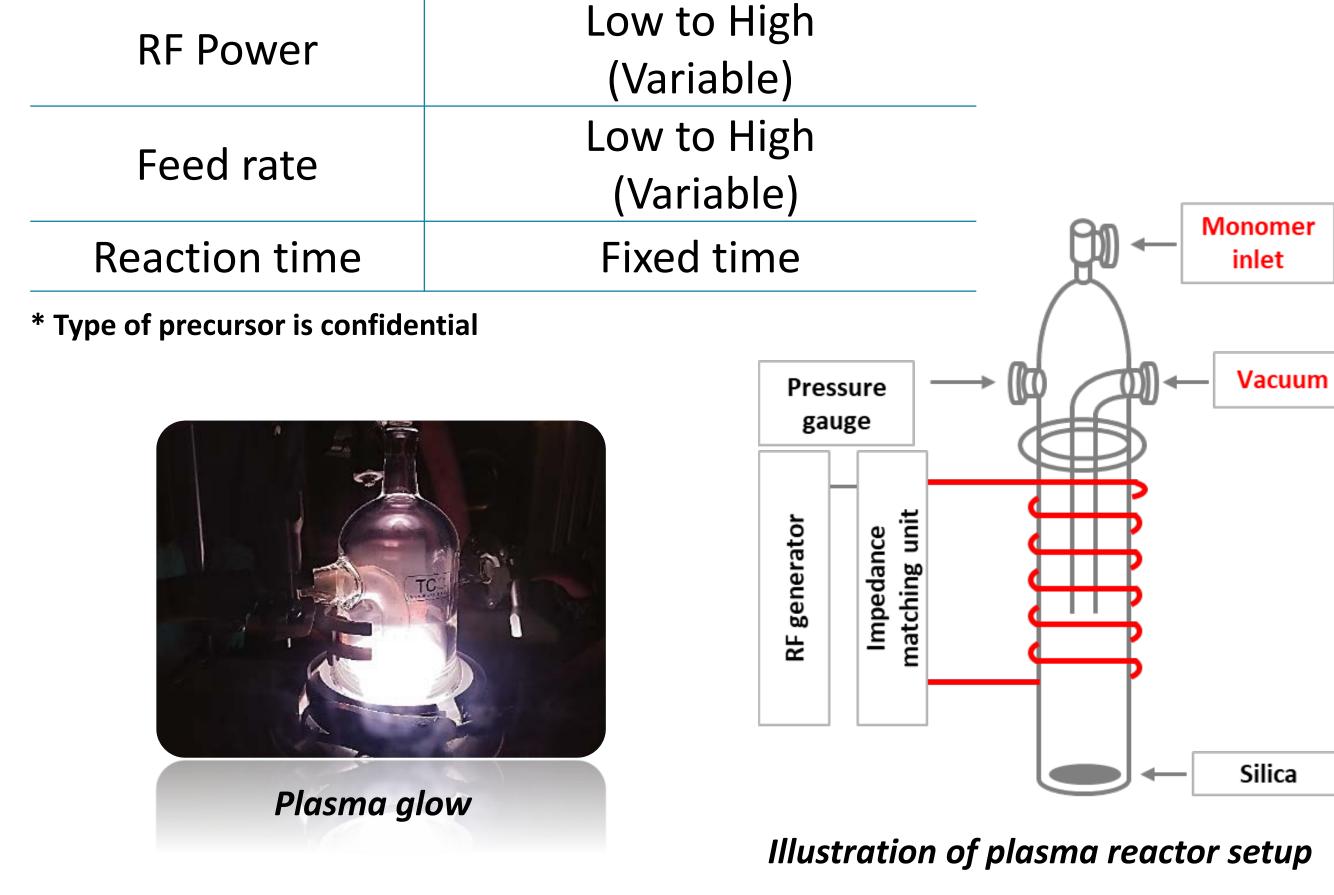


#### **Plasma treatment conditions**

#### **Thermogravimetric analysis (TGA)**



#### X-ray photoelectron spectroscopy (XPS)

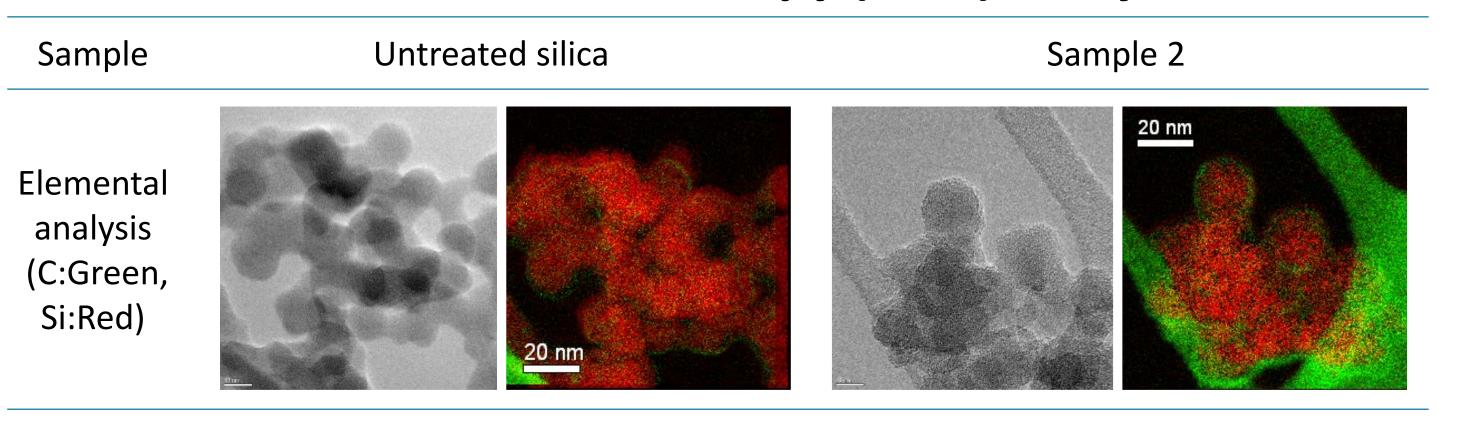


### Summary

• Plasma coated samples were prepared using a precursor and varying RF power and flow rate.

Sampla	С	0	Si	Ν	
Sample	%	%	%	%	
Untreated silica	1.1	69.8	29.1	0.0	
Sample 1	16.2	59.2	23.9	0.7	
Sample 2	28.1	51.0	20.7	0.2	

#### **Transmission electron microscopy (TEM) analysis**



NWO

- Characterization of coated samples was done by analytical tools such as TGA, XPS, TEM.
- Deposition of a hydrocarbon layer was successful and highest degree of deposition was observed at high RF power and high flow rate
- Layer thickness was in the lower nm range, but difficult to measure precisely by TEM

